

LISTING OF THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

1. - 24. (Canceled)

25. (Currently Amended) A substrate treating apparatus for removing photoresist film from a substrate by supplying a treating solution thereto, comprising:

a support means including a chuck rotatable by a motor for supporting and spinning said substrate in a horizontal plane;

an ozone water ~~a treating solution~~ supply means including a nozzle for supplying ozone water ~~said treating solution~~ having ozone dissolved in deionized water to an upper surface of said substrate;

an ultraviolet emitting means including UV lamps and a reflector for emitting ultraviolet light to said substrate, said ultraviolet emitting means emitting ultraviolet light under atmospheric conditions to said substrate from an irradiating position above said support means; and

a controller being structured to rotate ~~for rotating~~ said support means supporting said substrate, and to supply ~~the controller controls supplying~~ said ozone water ~~cleaning solution~~ from said nozzle of said ozone water ~~cleaning solution~~ supply means to a spin center of said substrate ~~to form a puddle on an upper surface of each substrate and the controller~~ being structured to control ~~controlling~~ supplying power to said UV lamps to emit ultraviolet light to said ~~cleaning solution~~ ozone water being supplied to said substrate during removal of the photoresist film and forming a puddle.

26. (Previously Presented) An apparatus as defined in claim 25, wherein the ultraviolet light has a wavelength in a range of 242.4 to 300nm.

27. (Previously Presented) An apparatus as defined in claim 25, including base adding means for adding a base to the treating solution.

28. (Previously Presented) An apparatus as defined in claim 26, including base adding means for adding a base to the treating solution.

29. - 37. (Canceled)